



US00D589473S

(12) **United States Design Patent**
Takamoto et al.

(10) **Patent No.:** **US D589,473 S**
(45) **Date of Patent:** **** Mar. 31, 2009**

(54) **ADHESIVE FILM MATERIAL FOR USE IN MANUFACTURING SEMICONDUCTORS**

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(**) Term: **14 Years**

(21) Appl. No.: **29/293,537**

(22) Filed: **Nov. 30, 2007**

(30) **Foreign Application Priority Data**

May 30, 2007	(JP)	2007-014404
May 30, 2007	(JP)	2007-014405
May 30, 2007	(JP)	2007-014407

(51) **LOC (9) Cl.** **13-03**

(52) **U.S. Cl.** **D13/182**

(58) **Field of Classification Search** D13/182;
29/25.35; 156/235, 248, 678; 257/678, E21.505;
310/340, 366; 438/133, 199, 450, 462
See application file for complete search history.

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(57) **CLAIM**

The ornamental design for adhesive film material for use in manufacturing semiconductors, as shown and described.

DESCRIPTION

FIG. 1 is a perspective view of a first embodiment of the adhesive film material for use in manufacturing semiconductors showing our new design;

FIG. 2 is a front view thereof;

FIG. 3 is a plan view thereof;

FIG. 4 is a right side view, the left side being a mirror image thereof;

FIG. 5 is an enlarged plan view of the design as identified by A and B in FIG. 2;

FIG. 6 is a sectional view taken along line 6—6 in FIG. 5;

FIG. 7 is a sectional view taken along line 7—7 in FIG. 5;

FIG. 8 is a perspective view of a second embodiment of the adhesive film material for use in manufacturing semiconductors;

FIG. 9 is a front view thereof;

FIG. 10 is a plan view thereof;

FIG. 11 is a right side view, the left side being a mirror image thereof;

FIG. 12 is an enlarged plan view of the design as identified by A and B in FIG. 9;

FIG. 13 is a sectional view taken along line 13—13 in FIG. 12;

FIG. 14 is a sectional view taken along line 14—14 in FIG. 12;

FIG. 15 is a perspective view of a third embodiment of the adhesive film material for use in manufacturing semiconductors;

FIG. 16 is a front view thereof;

FIG. 17 is a plan view thereof;

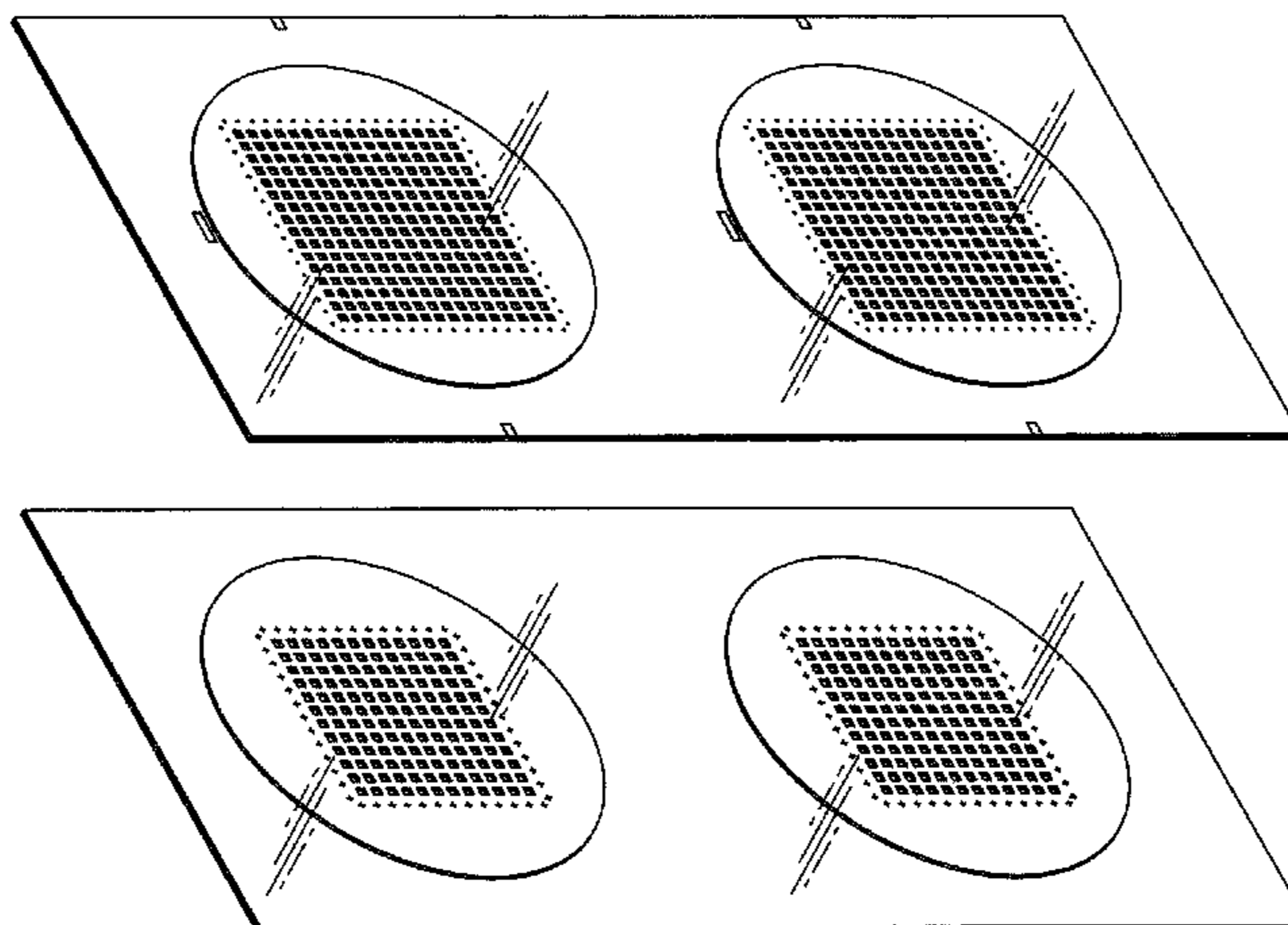
FIG. 18 is a right side view, the left side being a mirror image thereof;

FIG. 19 is an enlarged plan view of the design as identified by A and B in FIG. 16;

FIG. 20 is a sectional view taken along line 20—20 in FIG. 19; and,

FIG. 21 is a sectional view taken along line 21—21 in FIG. 19.

1 Claim, 9 Drawing Sheets



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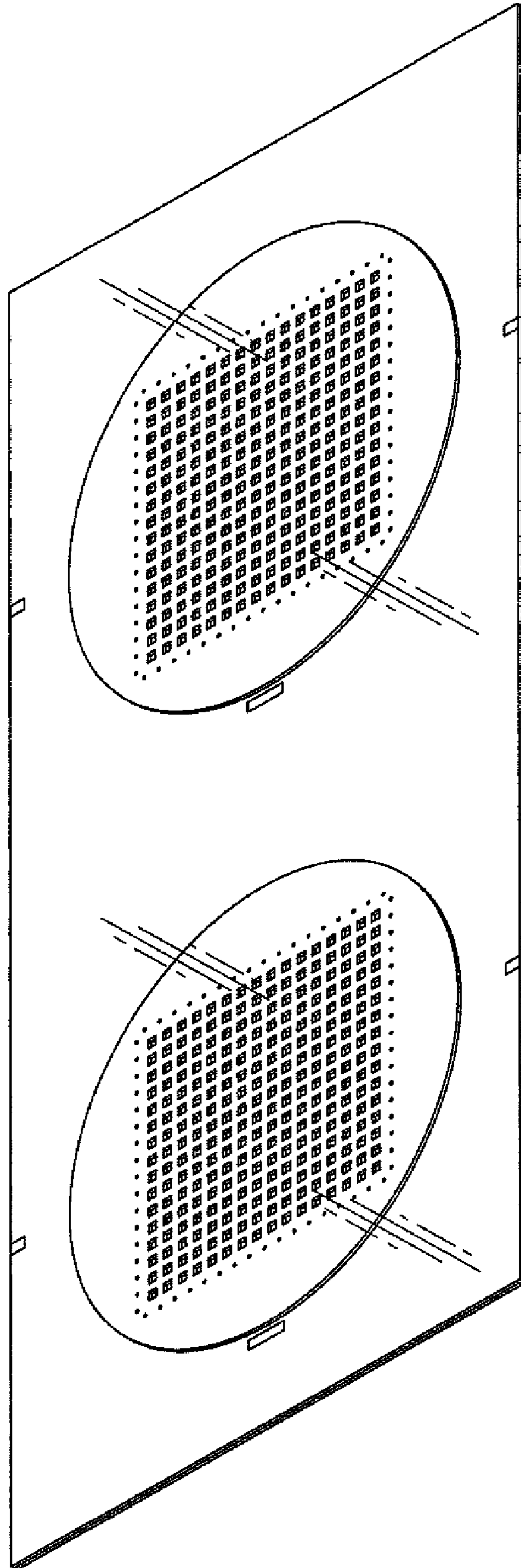


FIG. 1

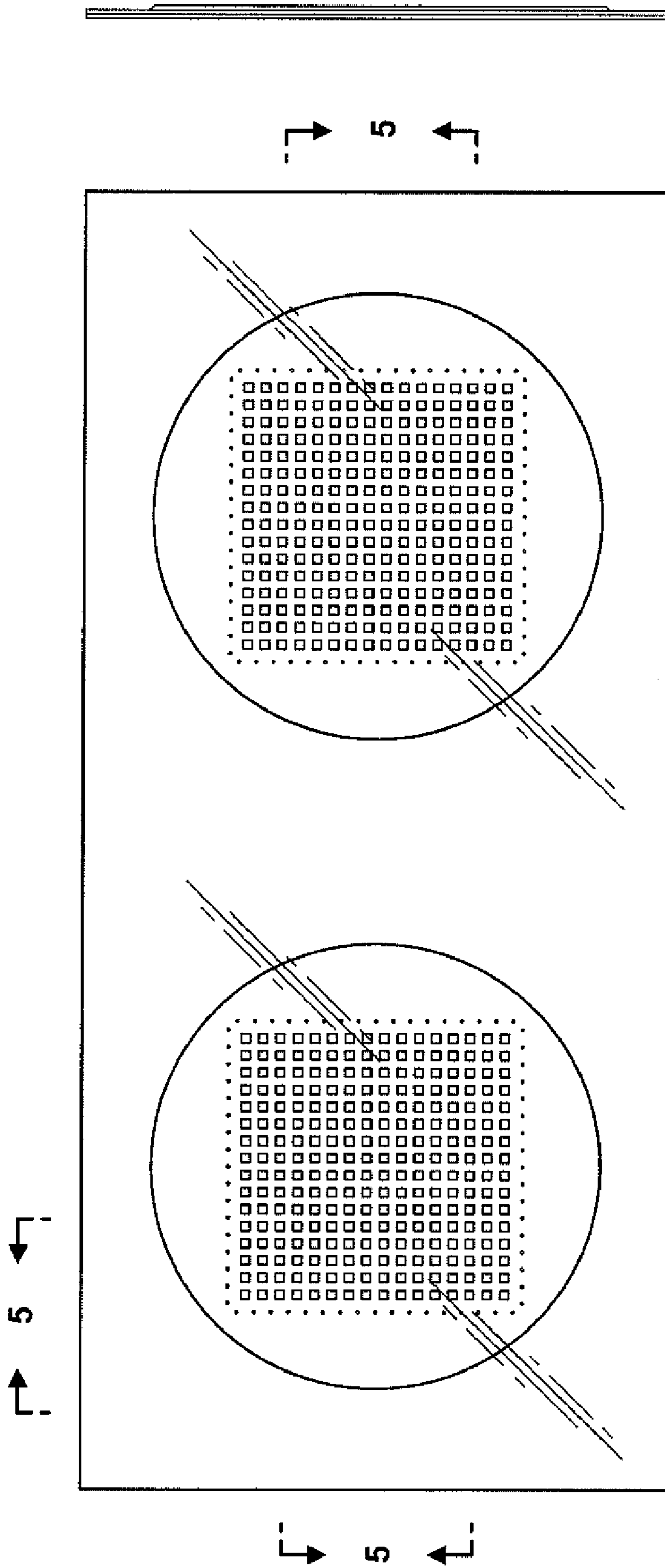
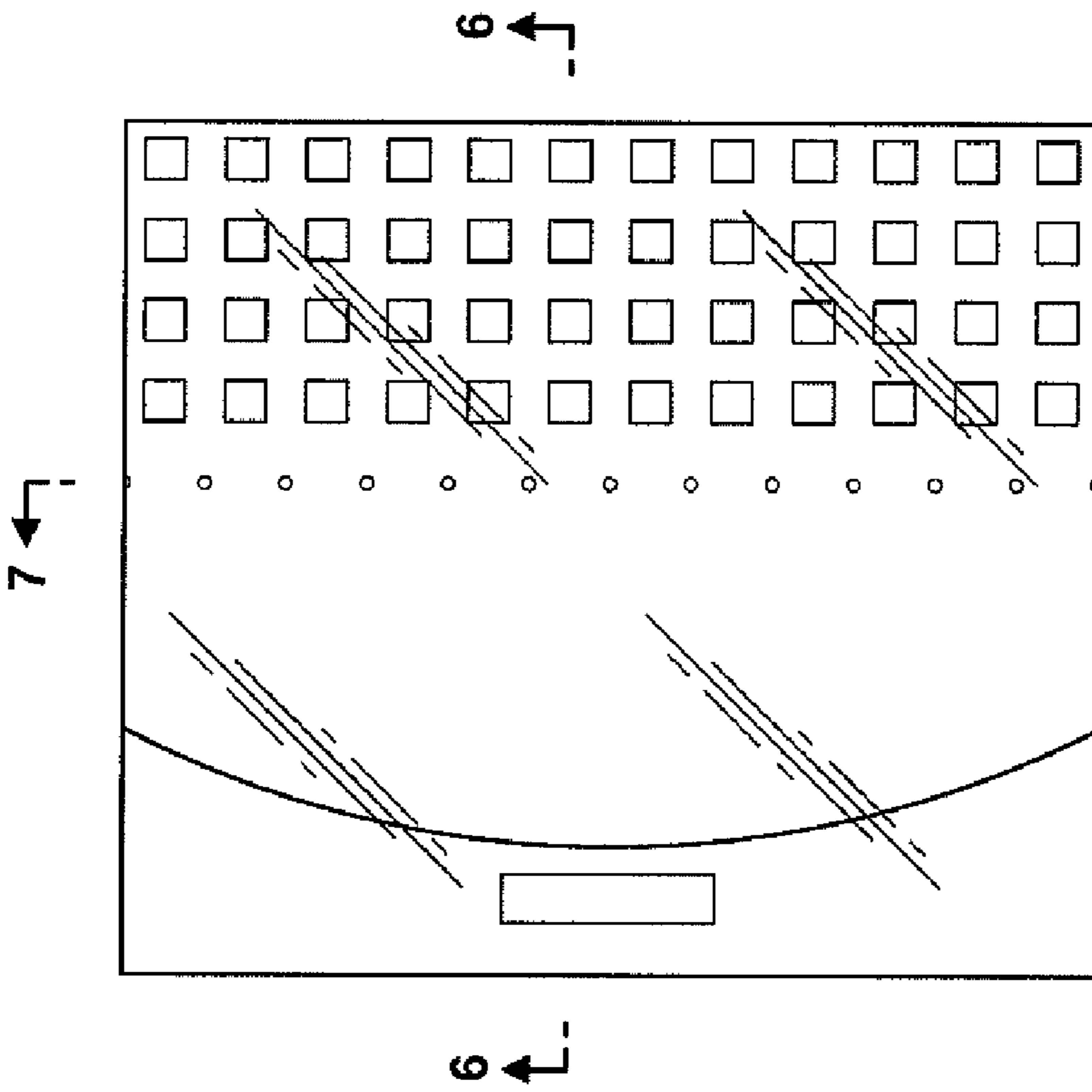


FIG. 4

FIG. 2

FIG. 3



7 ←
FIG. 5



FIG. 7



FIG. 6

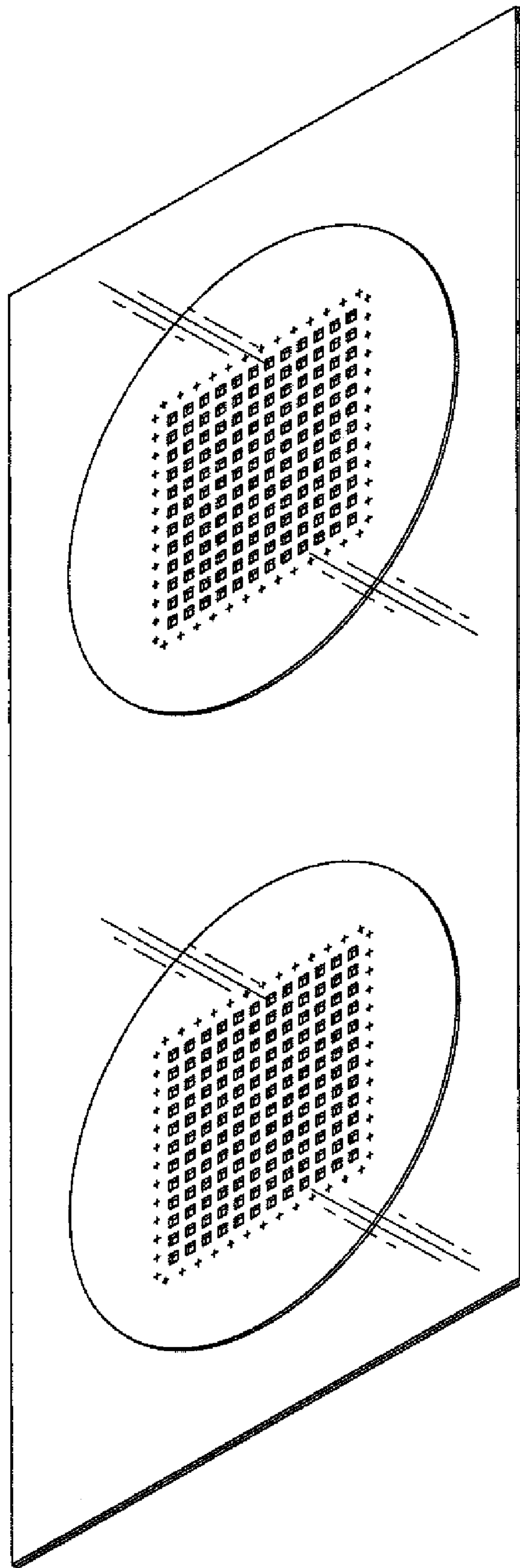


FIG. 8

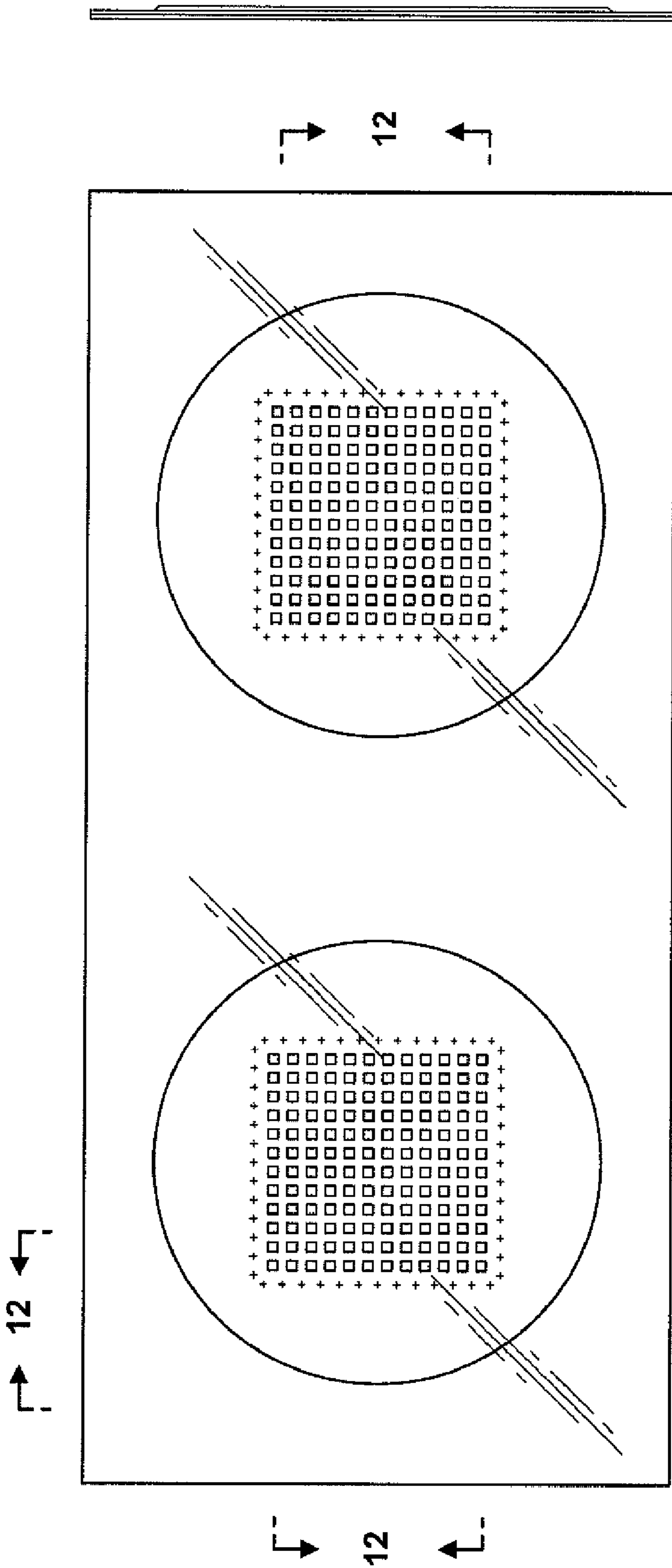


FIG. 11

FIG. 9

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FIG. 10

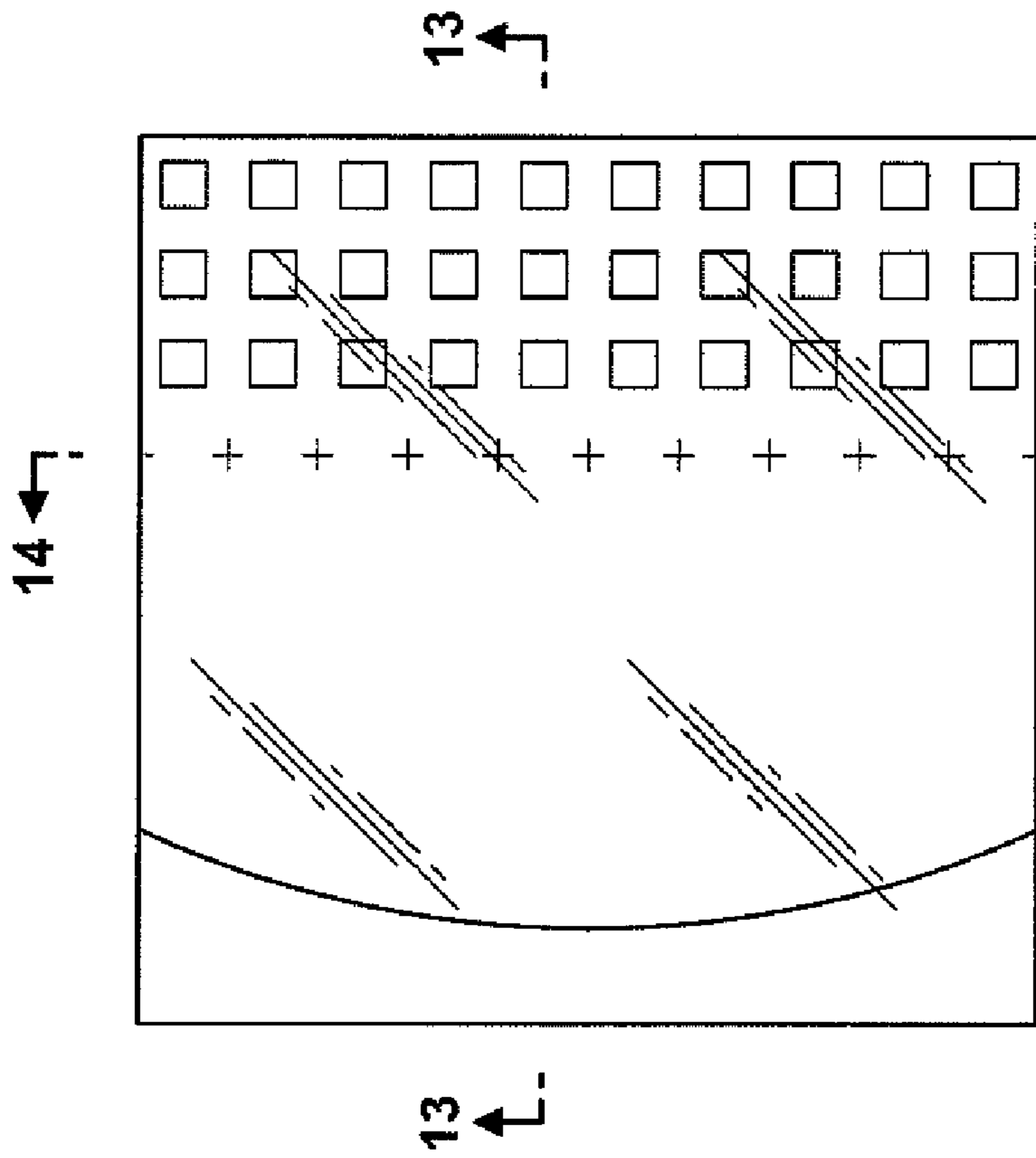


FIG. 14



FIG. 12



FIG. 13

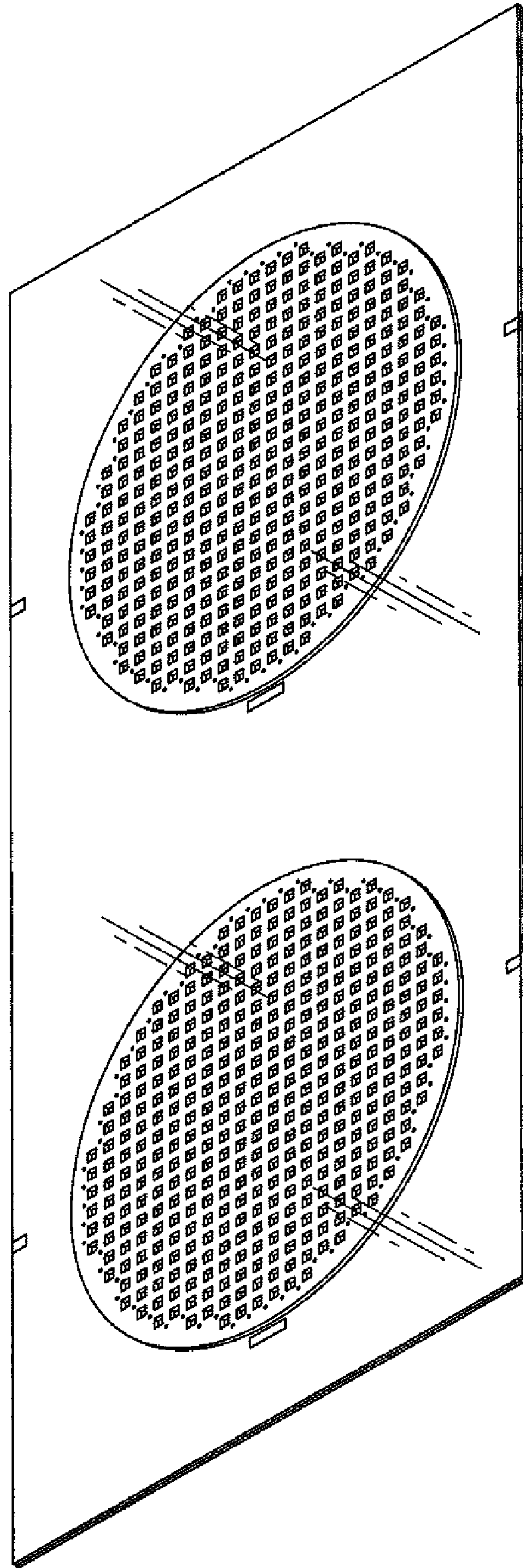


FIG. 15

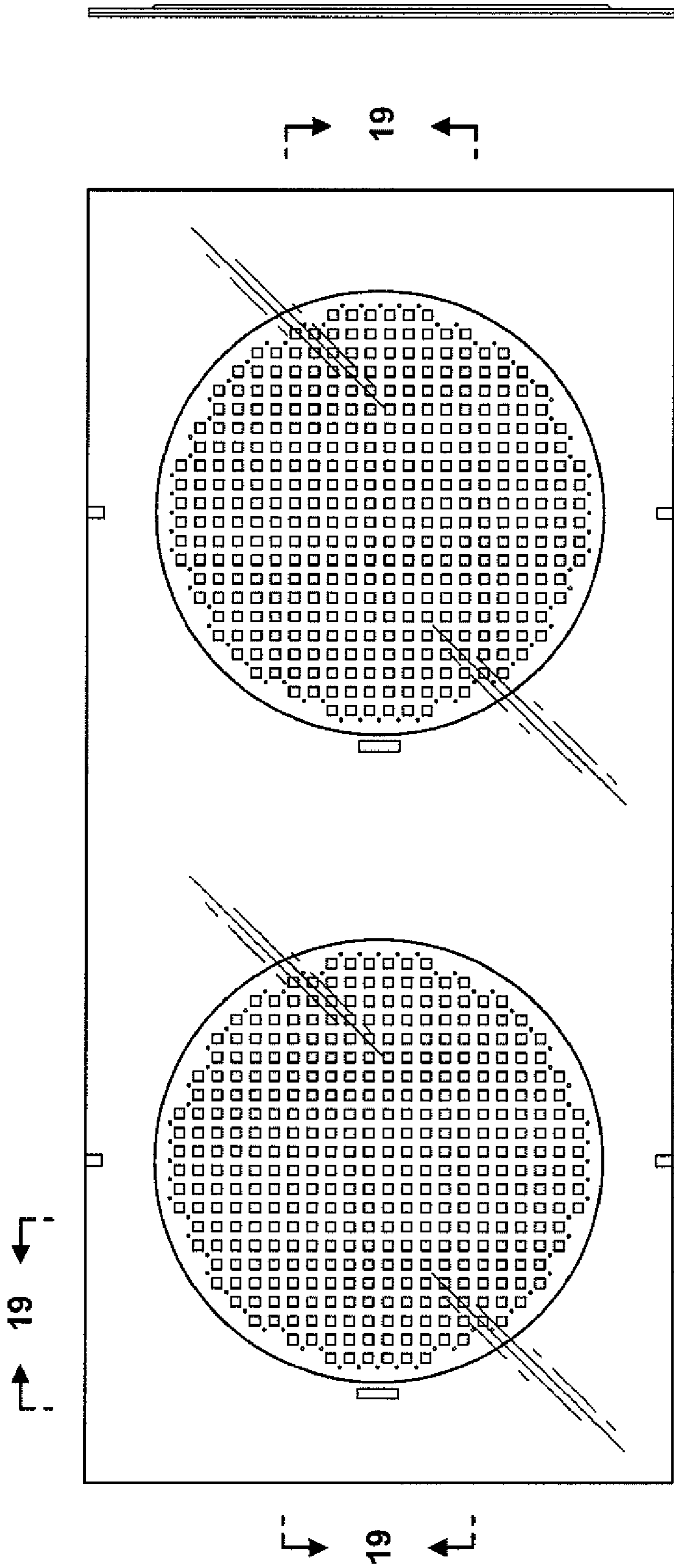


FIG. 18

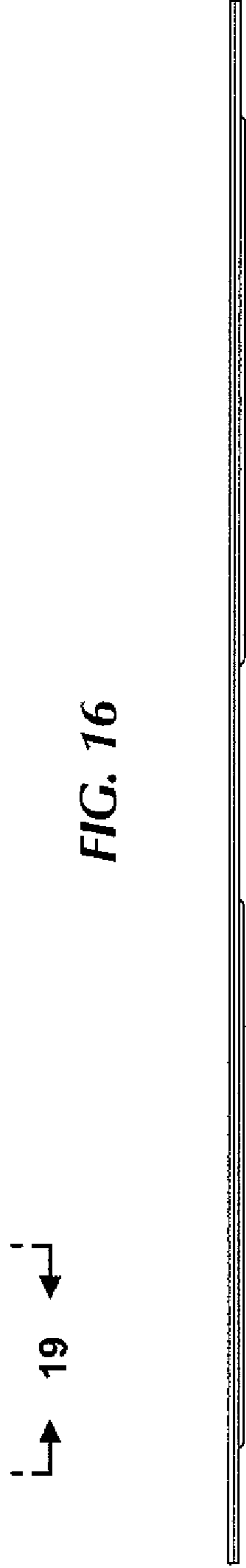


FIG. 16

FIG. 17

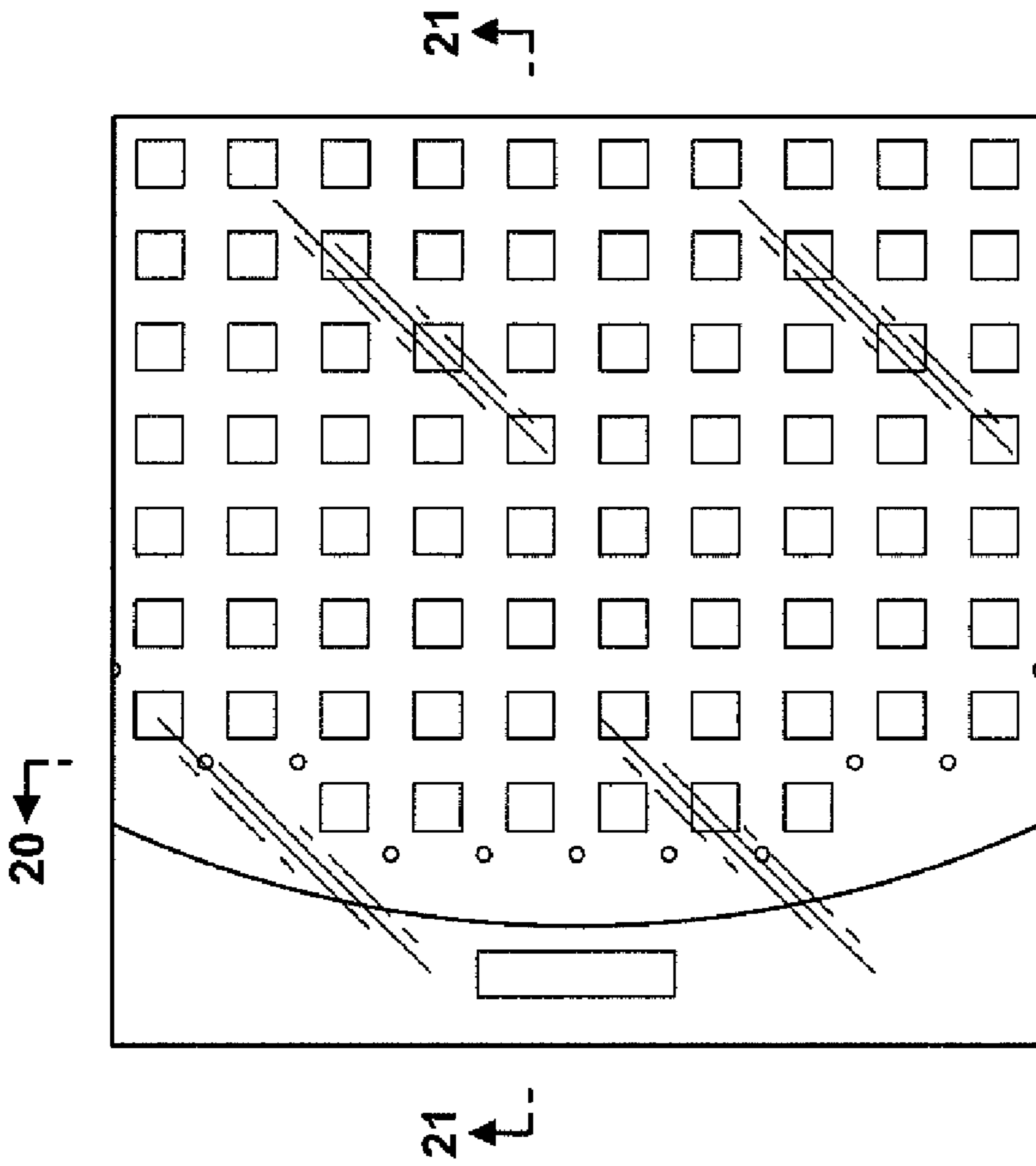


FIG. 21

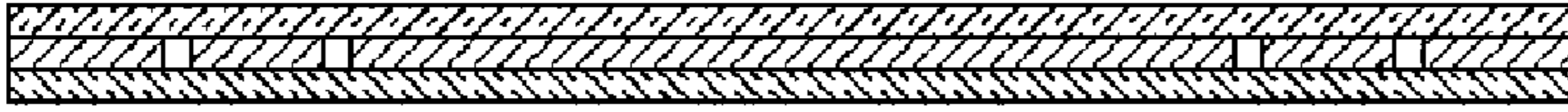


FIG. 20



FIG. 20